

<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>		Application No.	10/678,766
		Filing Date	October 2, 2003
		First Named Inventor	Tois et al.
		Art Unit	1722
(Multiple sheets used when necessary)		Examiner	Matthew J. Song
SHEET 1 OF 1		Attorney Docket No.	SEPP21.001C1

<b>U.S. PATENT DOCUMENTS</b>					
Examiner Initials	Cite No.	Document Number Number - Kind Code (if known) Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear

<b>FOREIGN PATENT DOCUMENTS</b>					
Examiner Initials	Cite No.	Foreign Patent Document Country Code-Number-Kind Code Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear

<b>NON PATENT LITERATURE DOCUMENTS</b>					
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.			
/MS/	1	NIEMINEN et al., "Formation and Stability of lanthanum oxide thin films deposited from $\beta$ -diketonate precursor" <i>Applied Surface Science</i> 6915: 1-12 (2001)			
/MS/	2	RITALA et al., "Zirconium dioxide thin films deposited by ALE using zirconium tetrachloride as precursor" <i>Applied Surface Science</i> 75: 333-340 (1994)			
/MS/	3	RITALA et al., "Growth of titanium dioxide thin films by atomic layer epitaxy" <i>Thin Solid Films</i> 225: 288-295 (1993)			
/MS/	4	PUTKONEN et al., "Low-Temperature ALE Deposition of Y <sub>2</sub> O <sub>3</sub> Thin films from $\beta$ -Diketonate Precursors" <i>Chemical Capor Deposition</i> 44-50 (2001)			
/MS/	5	LESKELÄ et al., "Atomic Layer Epitaxy in Deposition of Various Oxide and Nitride Thin Films" <i>Journal De Physique IV</i> Vol. 5: 937-951 (1995)			

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Examiner Signature	/Matthew Song/	Date Considered	01/17/2008
*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.			

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